International Collaboration Optical Test and Development

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Collaboration with VIRGO

- >> Alain Brillet Material Development and Specification
- >> Jean-Marie Mackowski Surface Characterization
- >> Claude Boccara Absorption, Birefringence, Wavefront Distortion
 - -Vincent Loriette
 - -Jean-Baptiste Daban
- >>Frederic Cleva Absorption



Material Development and Specification

VIRGO/Orsay - Alain Brillet

- VIRGO involved in development of low absorption (SV) Heraeus glass
 - >> Not ready at the time for commercial release
 - >>Better understanding/process control now than at the time of the LIGO material contracting
 - >> Could possibly use SV for future LIGO optics
- Review and comment on LIGO material specifications
 - >>specifying absorption in terms of OH content
 - >>For Heraeus glass < 300ppm OH implies < 5ppm/cm absorption at 1064 nm



Surface Characterization

VIRGO/IPN Lyon - Jean-Marie Mackowski

- LIGO assisted in characterization of VIRGO microroughness measuring instrument
 - >>Pathfinder optic polished at General Optics, coated at REO results were similar to those obtained during pathfinder metrology
 - >> Smaller substrates polished at General Optics
- Shared LIGO IR Interferometer specification



Birefringence, Surface Roughness, Wavefront Distortion, Absorption

VIRGO/ESPCI - Boccara, Loriette, Daban VIRGO/Orsay - Cleva

- Provided a characterized LIGO pathfinder optic A002 for intercomparison
- Provided 27 samples of various Fused Silica (Corning, Heraeus)

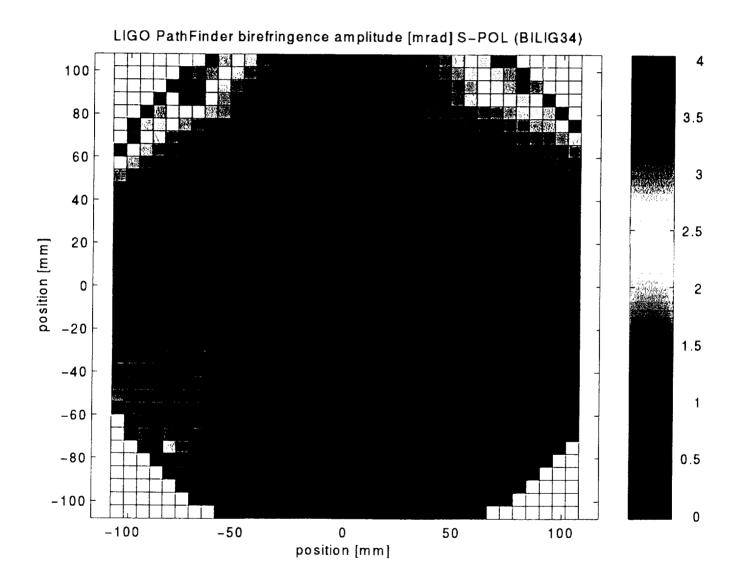


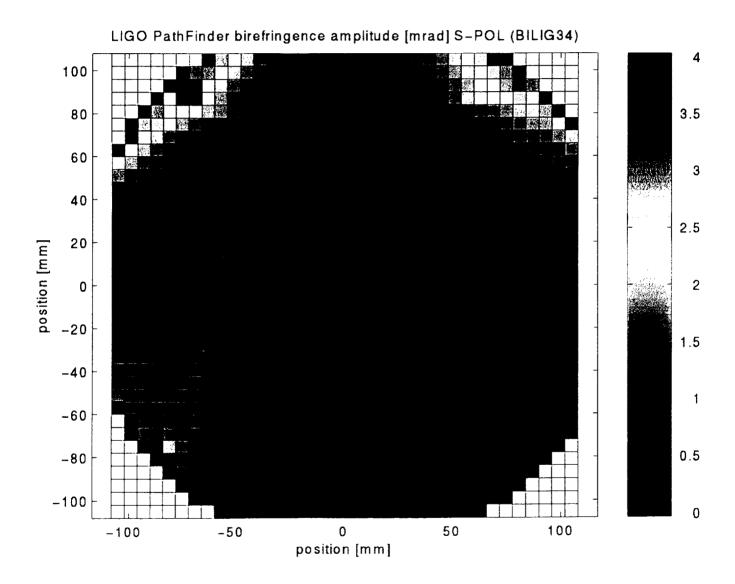
Birefringence

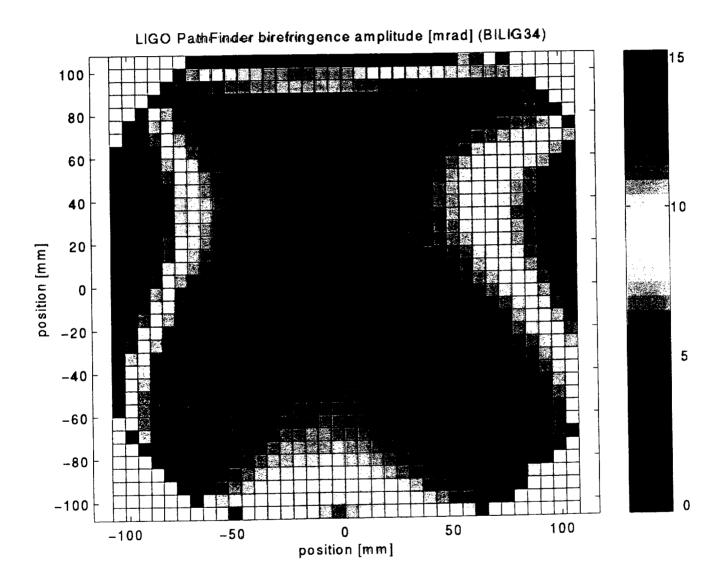
VIRGO/ESPCI

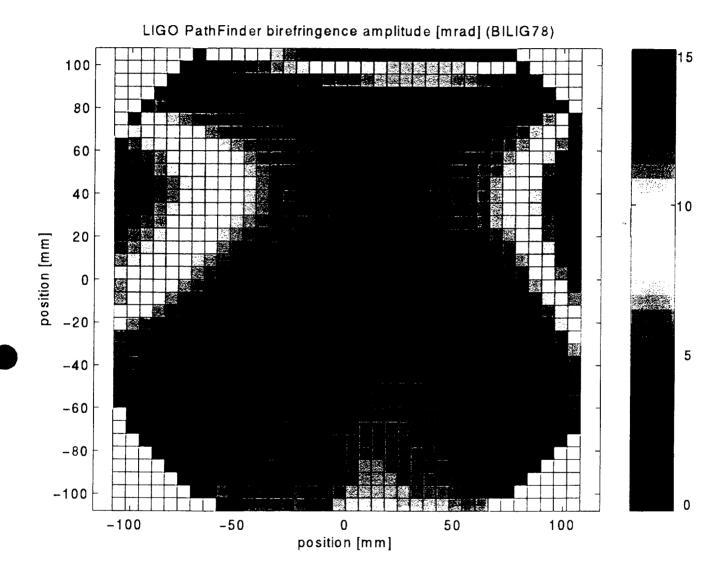
- Found to be induced by mounting/gravity (does not follow substrate rotation)
 - >> LIGO pathfinder A002 measured, ranges between 0 and 18 mrad when mounted in a "V" support.
 - >>Even mounted in this configuration the birefringence is found to be within the LIGO specification

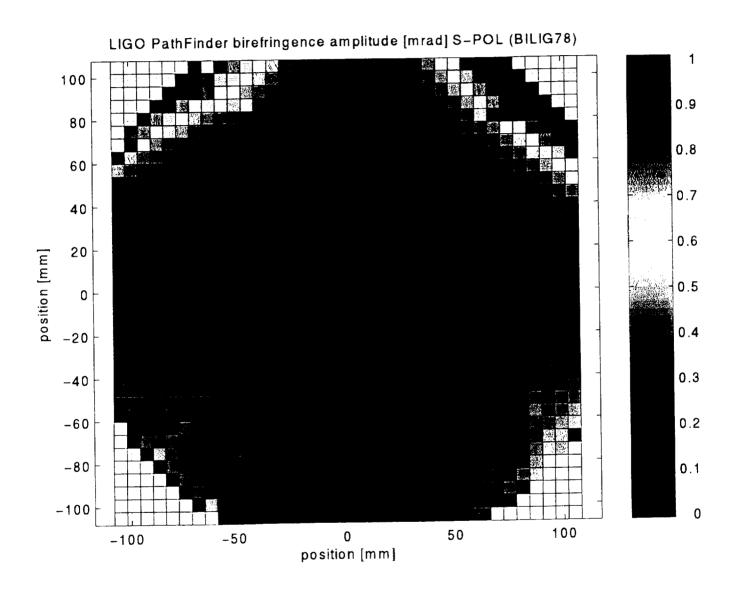












Surface Roughness

VIRGO/ESPCI

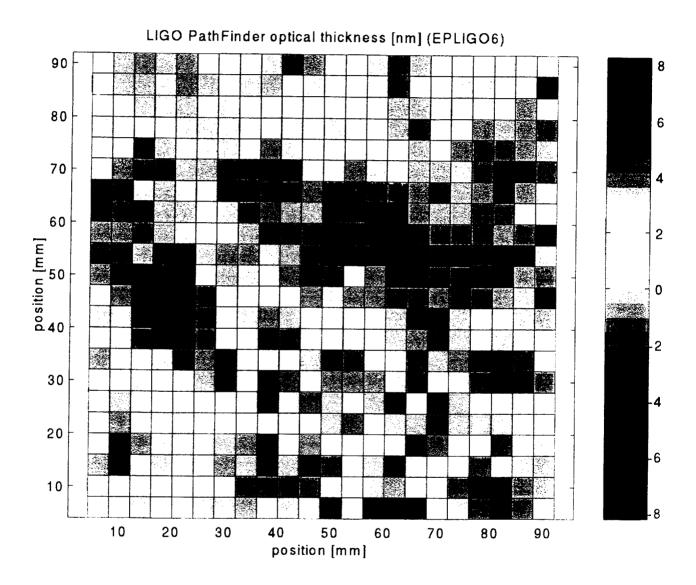
- Interferometric Microscope
- A002 measured
 - >> 3.0 nm rms
- Compare to
 - >>CSIRO measurement ~2.7 nm rms
 - >>REO measurement ~3.0 nm rms

Wavefront Distortion Optical thickness homogeneity

VIRGO/ESPCI

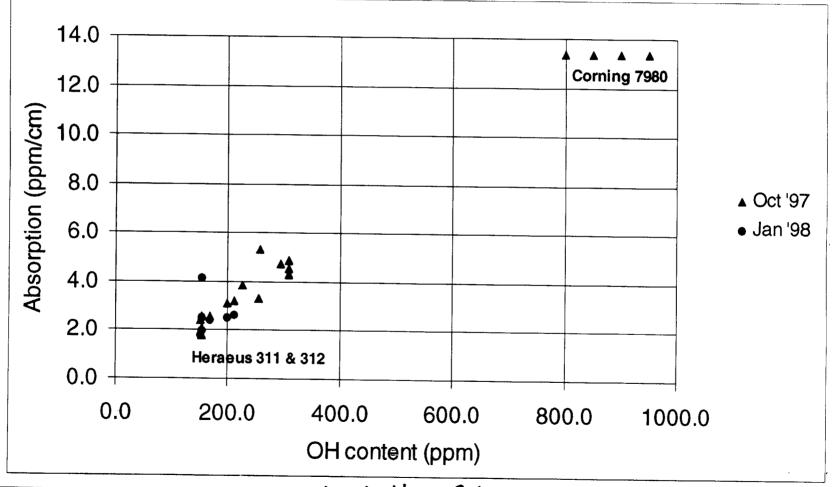
- Slope Measurement Technique
 - >> Raw Peak to Valley 36 nm
 - >> Corrected Peak to Valley ~10 nm
 - >>rms 2.7 nm





Absorption







CALIFORNIA INSTITUTE OF TECHNOLOGY
MASSACHUSETTS INSTITUTE OF TECHNOLOGY

Including SV glass
abs(ppm/cm)=1.2x102 OH(ppm)
V. Lariette

Heraeus Suprasil fused silica absorption vs. OH content

